

# HITACHI

Inspire the Next



Scanning Probe Microscope

**AFM5000 Series**



© Hitachi High-Tech Science Corporation

# Probe Station AFM5000II

Control System and Software **P.3**  
Measurement Modes **P.7**



Scanning Probe Microscope

## AFM5000 Series

Multifunctional Small Unit

### AFM5100N **P.13**

Desktop



Floor model



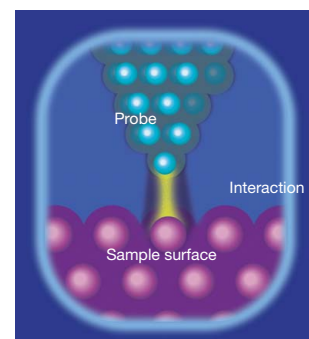


## Environment Control Unit AFM5300E P.15

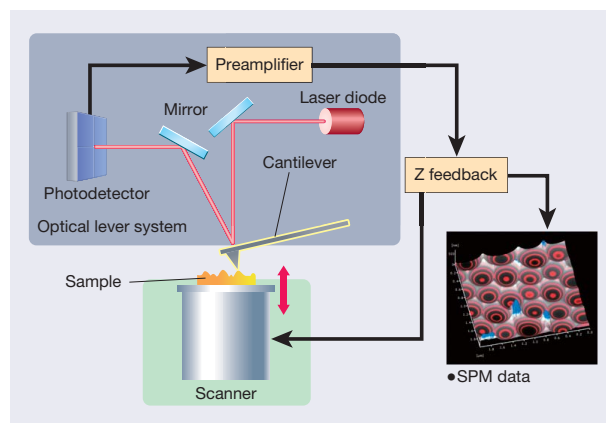


## Principle of Scanning Probe Microscope

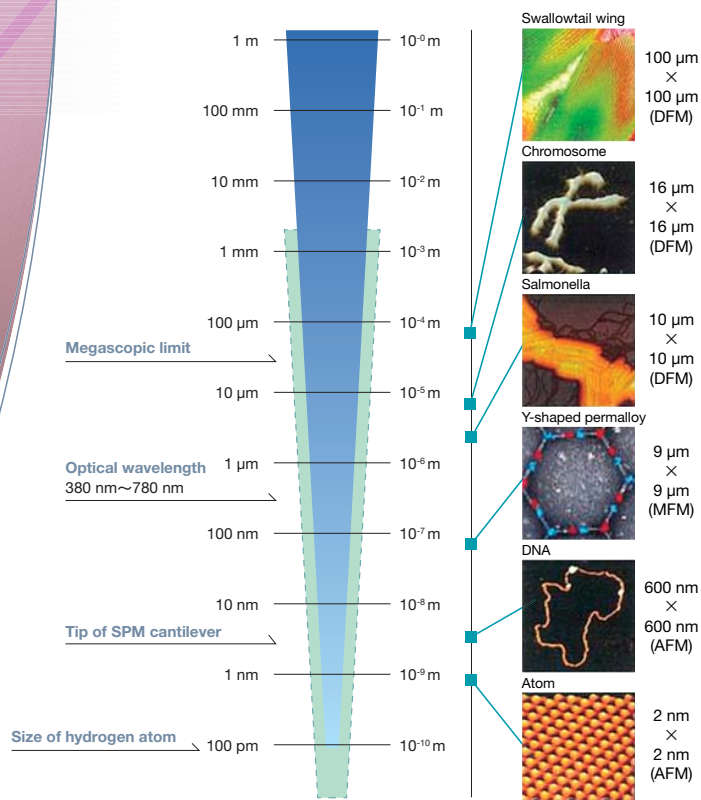
Scanning Probe Microscope (SPM) represents a particular family of advanced microscopy techniques that allow the simultaneous measurements of surface topography as well as a wide variety of material properties at nanometer scale. The two key members in this family are Scanning Tunneling Microscope (STM) and Atomic Force Microscope (AFM).



Schematic Diagram of SPM



## Observable Range of SPM



# Probe Station AFM5000II

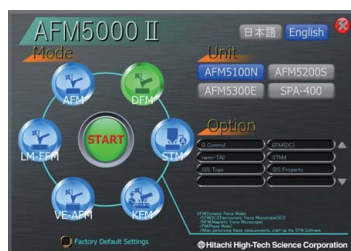


## GUI (Graphical User Interface)

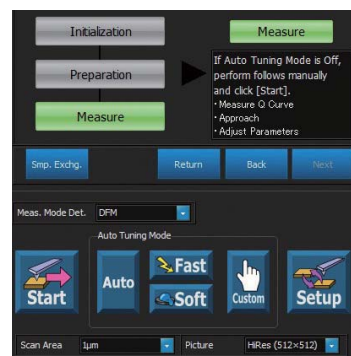
Intuitive and logical control icons balance the screen layout with information provided for ultraefficient, productive, and easy SPM operation for all levels of users.



Measurement



Mode Selector



Operation Instructions



Analysis

Measurement and analysis tabs provide organized and spacious work areas on the monitor display.



# RealTuneII

## Auto Tuning Functions for Optimal Measurement Parameters

The improved auto tuning function systematically and efficiently monitors sample topography, scanning area, the cantilever, and the scanner to determine the best operating conditions. As the measurement parameters are optimized, the cantilever's vibration amplitude and operation frequency are automatically adjusted based on the sample and cantilever type. The new and improved auto tuning algorithm offers reliable and precise images with a simple point-and-click!

### One-click automatic measurement

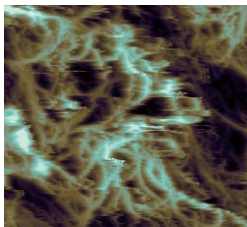


### Automatic tuning function examples

**Example 1**  
**Fibrous carbon nano-tube structure**  
 (Gecko adhesive tape, sample generously provided by Nitto Denko Corporation)

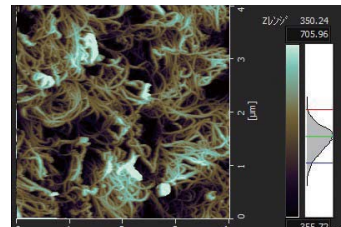
#### Conventional tuning system

Delicate fibers are deformed and damaged in cross directions.



#### Improved algorithm

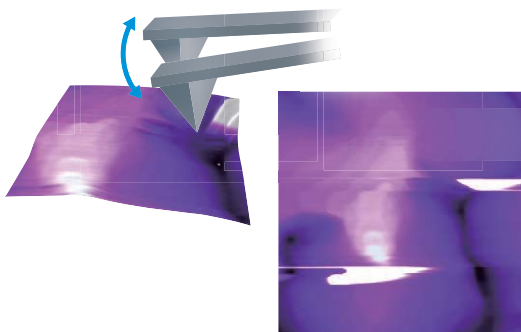
The complex fiber structure is clearly observed without damage.



**Example 2**  
**Polycrystalline organic thin-film transistor**  
 (Polycrystalline pentacene thin film, sample generously provided by Kitamura Laboratory, Kobe University)

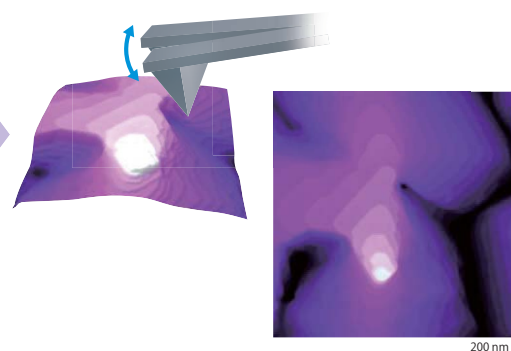
#### Conventional recommendation value

The crystal steps are destroyed and unclear.



#### Improved algorithm

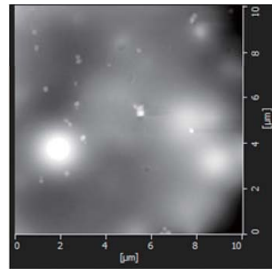
Stable observation of the crystal steps by the improved tuning function.



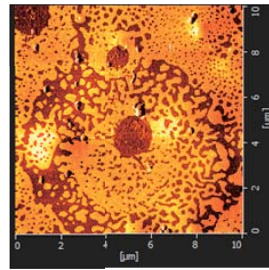
## Various Analysis Functions

### 3D overlay

The 3D overlay image of an oil film on a polyethylene sheet's topography and VE-AFM (Viscoelastic-AFM).



Topography



VE-AFM



3D overlay image



### Roughness and cross-section profile analysis

The 3D Overlay Function enables the observation of “cause and effect relationship” between topography and physical properties. A variety of other functions, such as roughness and cross-section analysis, are also standard tools.

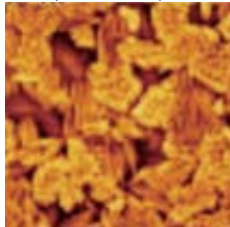
## Tip Calibration

Tip Calibration improves reliability and validity of obtained data, since the resolution of SPM data greatly depends on the sharpness of the tip. When the tip is deformed or contaminated, its shape affects the result of topographic image.

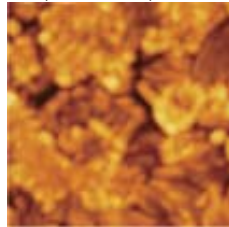
Example

ITO thin films scanned with a new probe (left) and worn out probe (right)

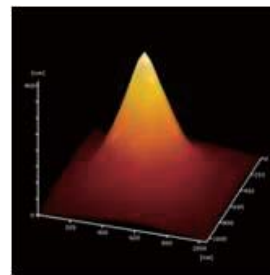
Pass (Ra: 7.65 nm)



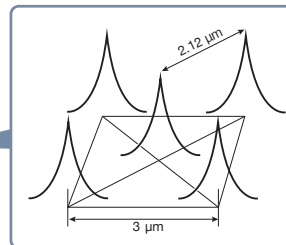
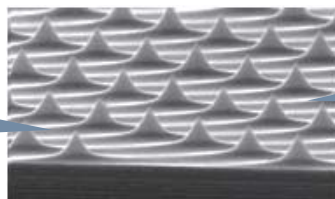
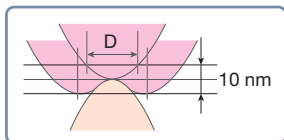
Fail (Ra: 5.77 nm)



### Tip calibration result



### Tip calibration standard sample





# Q Control

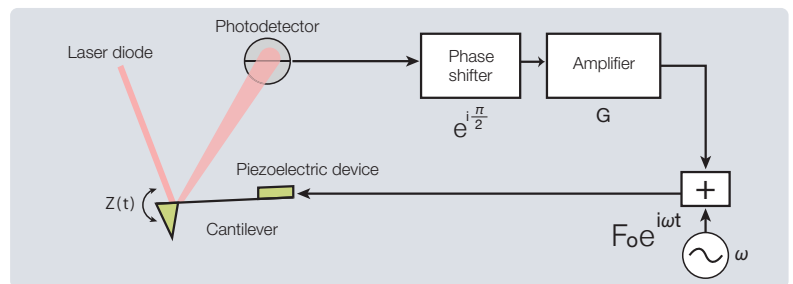
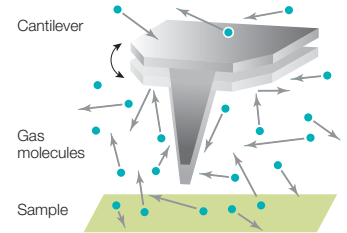
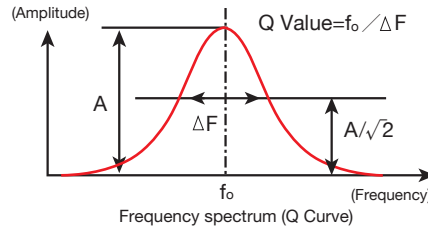
## Benefits

- High sensitivity measurement both in air and vacuum
- High speed response in vacuum
- Enhanced force measurement in solution

Sharpness of the frequency spectrum for an oscillating cantilever can be characterized and quantified by the Q factor, which is proportional to the sensitivity of the force gradient detection. Higher Q values imply an enhanced sensitivity to the variations of the tip-to-surface forces as well as a faster response of the system. Typically, the hydrodynamic damping with the medium reduces the Q. Therefore, Q control can be used to improve the performances in a medium.

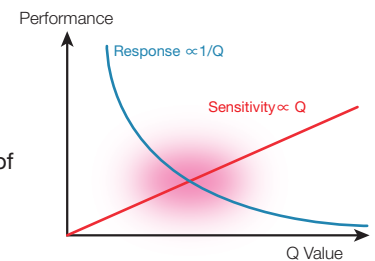
Q control uses a phase shifter and amplifier to regulate the actual oscillation of a cantilever.

The cantilever signal is amplified, phase shifted by  $\pi/2$ , and then feedback for cantilever excitations, thus to modify its vibration. When the amplification factor "G" is positive, it leads to an increase of the Q factor.



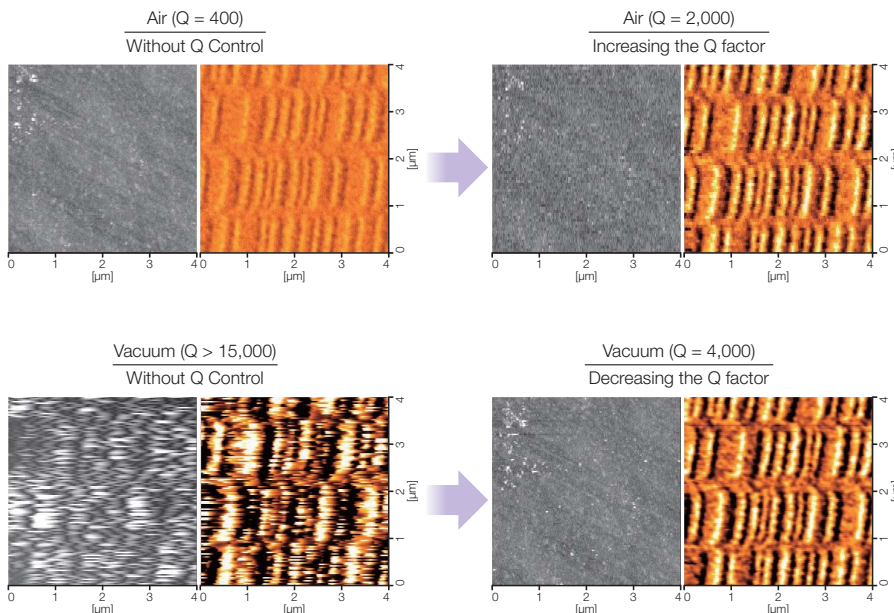
Q Control balances both sensitivity and responsiveness.

Measurements under vacuum are best suited for electromagnetic modes and avoiding the influence of adsorbed water. However, when the Q factor is too high, it reduces the responsiveness (stability).



## Example 1

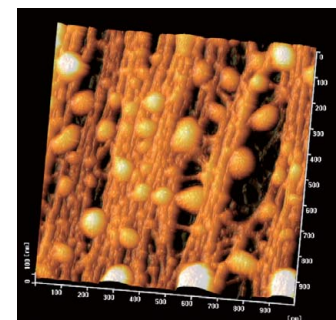
### MFM observation of magnetic recording on a hard disk



## Example 2

### DFM observation of hollow fiber membrane in liquid

Showing below is a DFM topography image of a hollow fiber membrane that is widely involved in medical applications. The surface contains some very soft hydrated film protrusions. Despite the extreme challenges, such delicate and fragile features can be resolved clearly by gentle imaging with enhanced force detection via effective Q control.



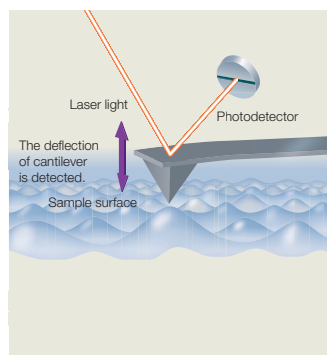
# Measurement Modes

## Topography

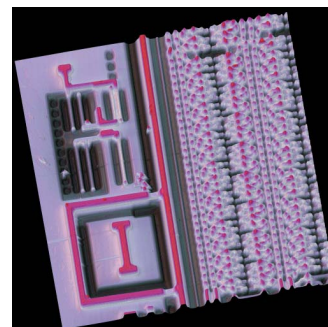
### Atomic Force Microscope (AFM) / Contact Mode



For contact mode AFM, the force between probe and sample is detected and measured via cantilever's deflection. A feedback system will maintain this deflection constant while scanning the sample surface to observe topography.



Semiconductor circuit

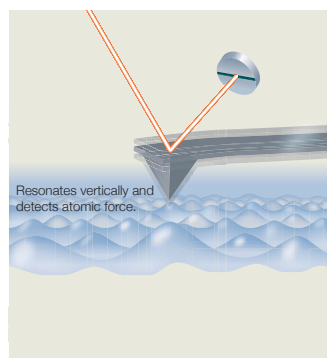


Scan area: 100  $\mu\text{m}$

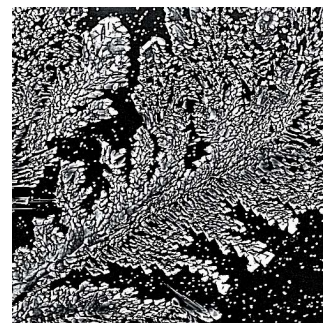
### Dynamic Force Microscope (DFM)



For DFM, the cantilever is oscillating while it approaches to the sample surface. The force between probe and sample is reflected by cantilever amplitude change and maintained to be constant while scanning and observing the sample surface.



Dendrite



Scan area: 30  $\mu\text{m}$

### Scanning Tunneling Microscope (STM)



A tunnel current flowing between probe and sample is detected (controlled so that the tunnel current is fixed and sample surface is scanned) by applying a bias voltage between a metallic probe and conductive or semiconductive sample as the distance between them approaches less than several nm. Sample topography as well as its electronic state are observed.

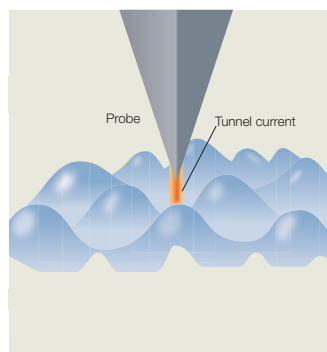
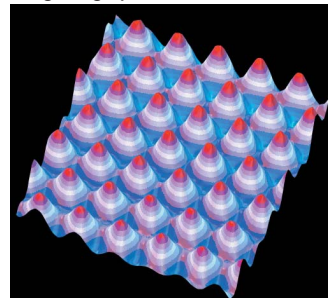


Image of graphite atoms



Scan area: 3 nm



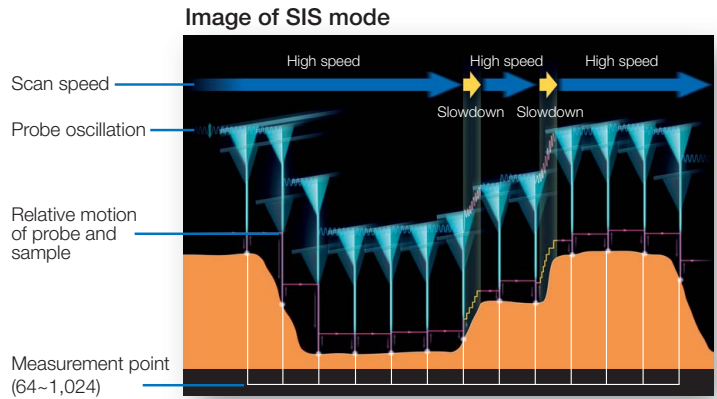
## Sampling Intelligent Scan (SIS)



In SIS mode, probe approaches each measurement point and acquires topography and physical property information, followed by retracting from the sample and moving to the next measurement point. It is an intelligent measurement mode that can adjust the scan speed according to sample surface. SIS solved problems occurred in conventional SPM by reducing the lateral tip/sample interactions. This enables stabilized measurements, particularly on soft and adhesive samples as well as samples with high aspect ratio structures. When used in the Current Mode for a soft material, SIS allows the stable acquisition of topographic image without damaging the sample. SIS is also effective in the Phase Mode (PM): SIS-PM eliminates the effects of sample topography, which may cause artifacts in PM imaging.

### Conceptual diagram of SIS-Topo\* scanning movements

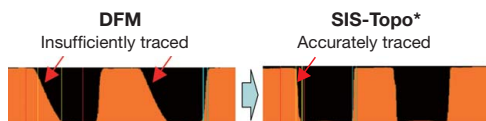
Probe and sample make contact only when getting data. Aside from this, scanning speed drops when moving at high speeds in the horizontal direction while on stand by in mid-air and when in contact with the sample surface; and shelter motions that rise from the sample surface are automatically performed.



### SIS-Topo\* Examples

#### Measuring deep trenches

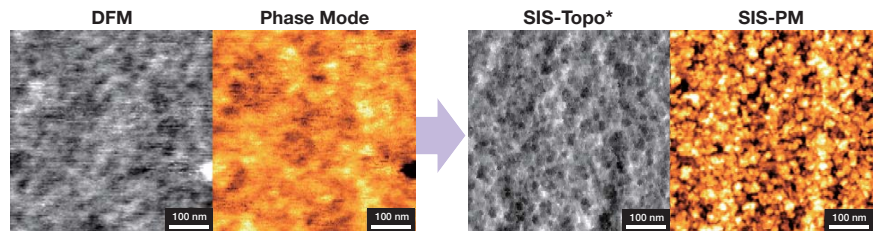
**Example 1** Comparison between DFM and SIS-Topo: Measuring deep trenches by using conventional DFM cantilevers



SIS-Topo\* eliminates effects from horizontal direction and accurately scans trench walls.

#### Observation of adhesives

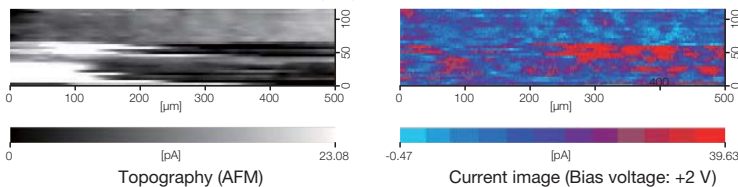
**Example 2** DFM cannot get a clear image of the phase or the topography of soft and adhesive surfaces; however, SIS-Topo clearly observes both topography and phase images.



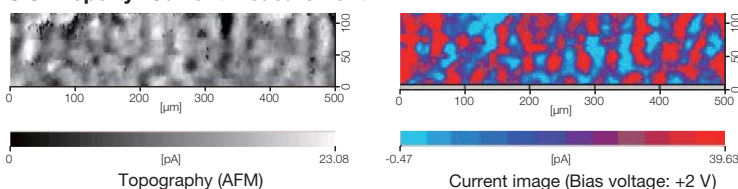
### SIS-Property\* Example

**Example**

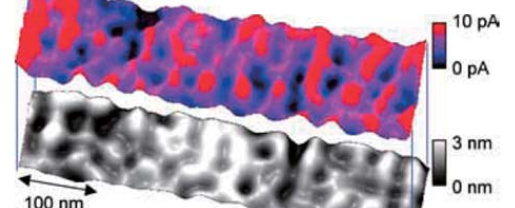
#### Conventional AFM/Current imaging



#### SIS-Property\* Current measurement



#### Current image (3D image)



#### Surface topography (3D image)

The conventional current and AFM modes deform samples, resulting in an unstable image reflected in the scan direction for current distribution. In contrast, SIS-Property\* (Current) performs stabilized measurements for both current and topographic images without deforming the sample.

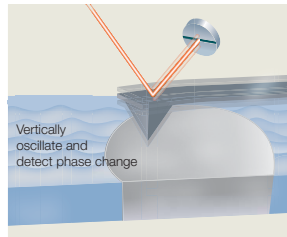
\*SIS-Topo is for observing topography and phase mode, while SIS-Property is for mechanical and electromagnetic property measurements.

# Mechanical Property

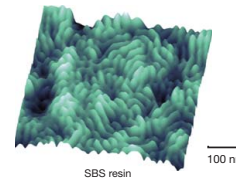
## Phase Mode (PM)



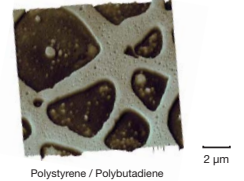
The DFM measurement detects phase lag in oscillation of the cantilever depending on the size of adsorptive power or hardness and softness, and observes differences in physical properties of the sample surface.



Microphase separation phase image



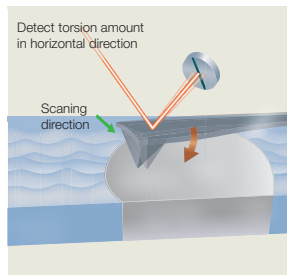
Polymer blend phase image



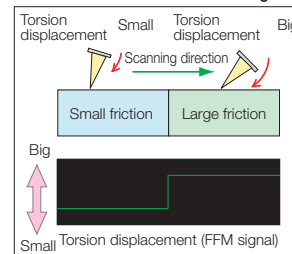
## Friction Force Microscope (FFM)



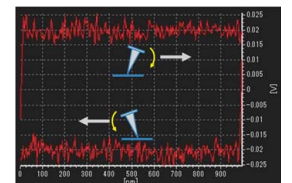
The sample is scanned in the direction in which the cantilever is twisted. Frictional force, occurring between probe and sample, is converted into cantilever's torsion which is simultaneously detected as frictional and topographic images.



Cantilever movement and FFM signal



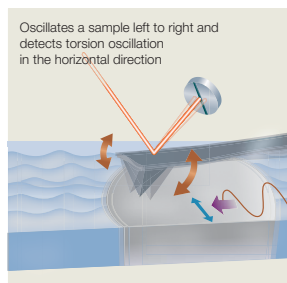
Frictional curve



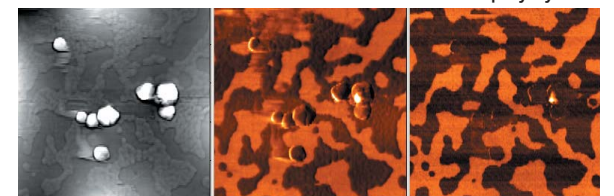
## Lateral Modulation FFM (LM-FFM)



Friction image that does not rely on surface unevenness or scan direction by adding micro oscillations in the horizontal direction (direction of cantilever deflection) to the sample is observed and the torsion oscillation of the cantilever is detected.



Friction distribution measurement of silicon oil film on polystyrene

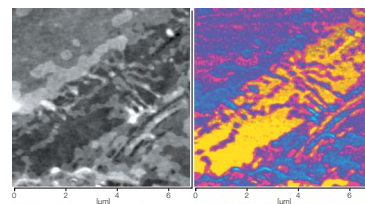
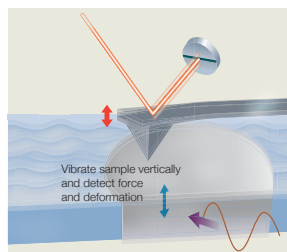


Friction of oil film is less, resulting in dark contrast in FFM and LM-FFM images. Scan area: 2.5 μm

## ViscoElastic AFM (VE-AFM) / Force Modulation Microscope



VE-AFM observes viscoelasticity image by adding vertical micro-oscillations in a sample and detects deflection oscillations (oscillation in the vertical direction) of the cantilever that change by differences in surface viscoelasticity.



Viscoelasticity distribution measurement of dispersed coating on a polyethylene film

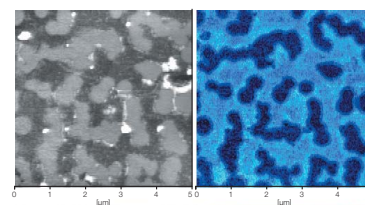
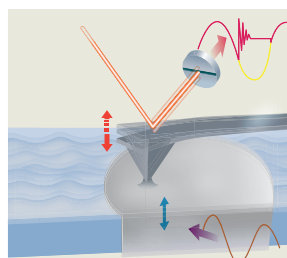
The polystyrene substrate is harder than the coating.

Scan area: 7 μm

## Adhesion



It micro-oscillates the sample in the vertical direction; repeats the movement that the probe and sample contact and separate periodically; detects the deflection of the cantilever at the moment that the probe is separated from the sample; and observes adsorption power distribution.



Adhesive force distribution measurement of Langmuir-Brodgett film

It can be observed that adhesive force of fluorine series film is less on Si boards.

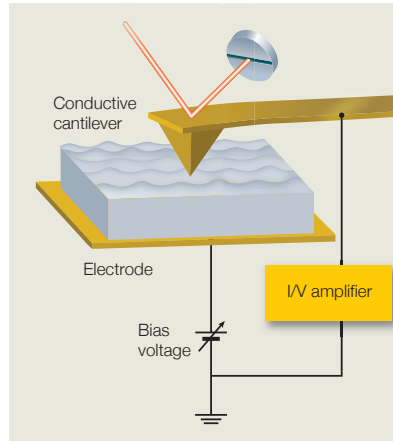
Scan area: 5 μm



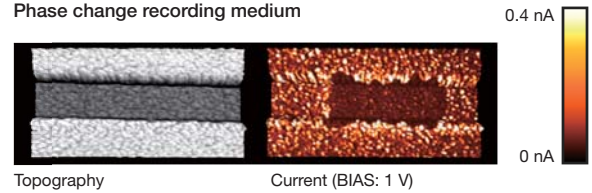
## Electromagnetic Property

### Current/Pico-current

Scans in the horizontal direction with a bias voltage applied to the sample, detects the current that flows between probe and sample, and observes current distribution.

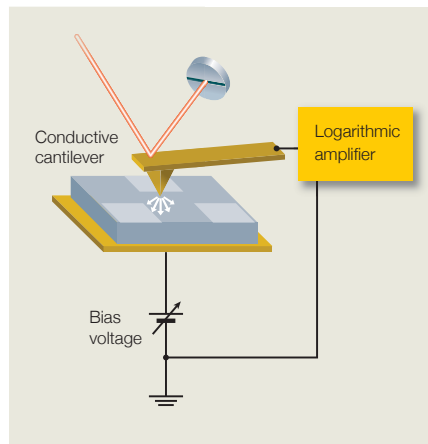


Phase change recording medium

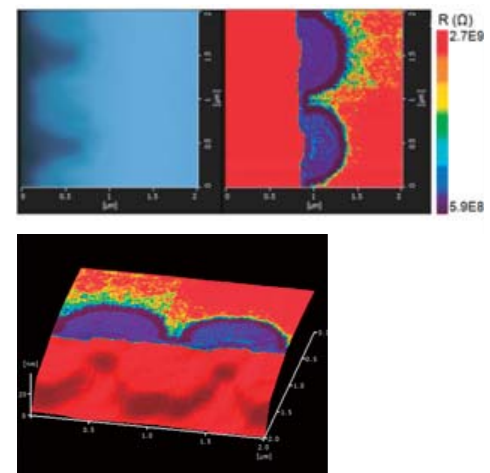


### Scanning Spread Resistance Microscope (SSRM)

Local resistance distribution on the sample surface at the wide range amplifier greater than 6th order is observed by using a hard cantilever of high conductivity and measuring the micro-current at the contact position with the probe by applying a bias voltage to the sample. The practical semiconductor dopant concentration range is sufficiently covered.



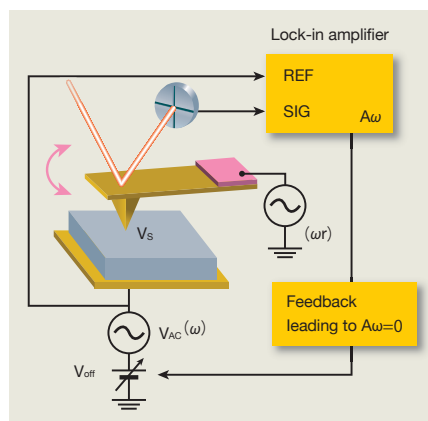
Mos transistor



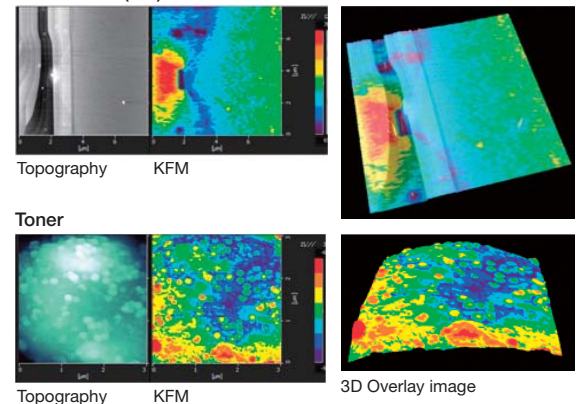
### Kelvin Probe Force Microscope (KFM)

Measures the surface potential by the feedback DC voltage by applying AC as well as DC voltages between a conductive cantilever and sample so that the amplitude of the static force component from the AC voltage is zero.

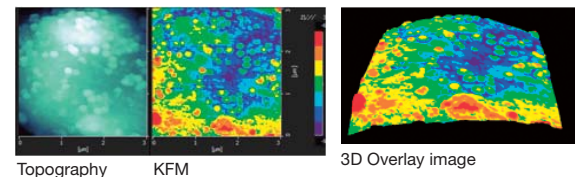
- CC-KFM (Cyclic contact KFM)
- NC-KFM (Non-contact KFM)



Laser diode (InP)



Toner



# Electromagnetic Property

## Electrostatic Force Microscope (EFM)

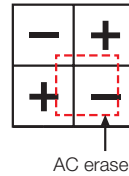


Applies an AC or DC voltage between a conductive cantilever and sample and creates an image of the electrostatic force components (amplitude component and phase component) by an AC voltage.

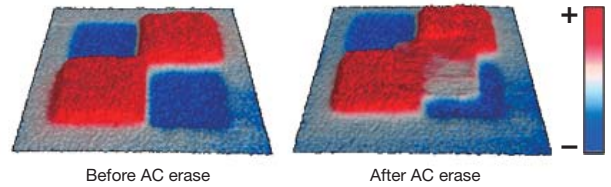
- EFM (AC)...AC field response
- EFM (DC)...DC field response

KFM directly detects potential of sample surfaces.

EFM does not directly detect surface potential but has better responsiveness than KFM and is convenient for imaging qualitative electrical properties.



Ferroelectric polarization patterns

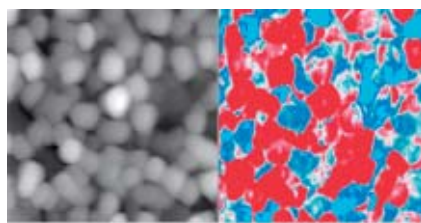


## Piezo-Response Microscope (PRM)



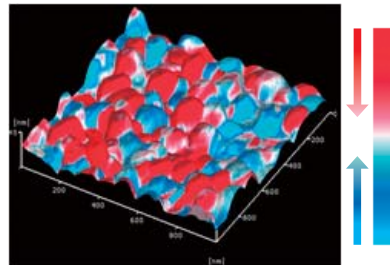
Applies an AC current between the probe and sample, and by scanning, observes strain distribution of the sample while detecting the ferroelectric strain component.

Ferroelectric thin film

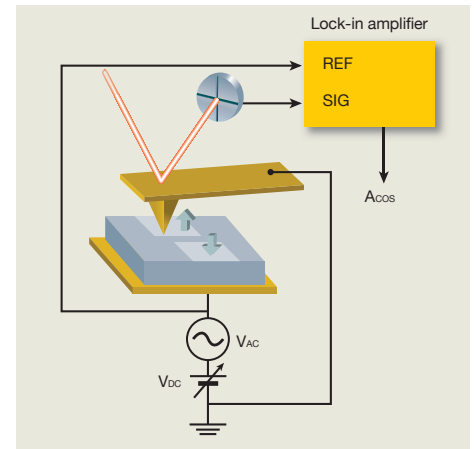


Topography

PRM



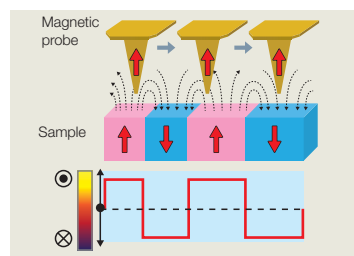
3D overlay image



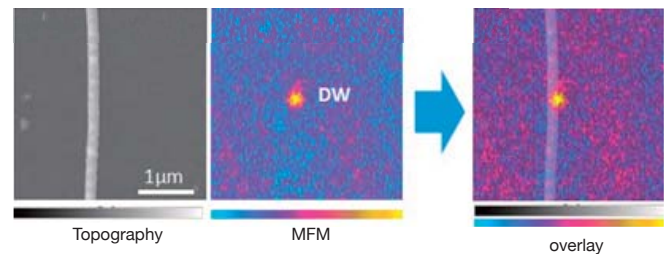
## Magnetic Force Microscope (MFM) [Received the Magnetic Society of Japan Best Paper Award (2003 & 2005)]



A magnetic action between magnetic probe and sample is produced and imaged as potential changes in cantilever oscillation. High sensitivity and high resolution magnetic domain imaging is possible by measuring in vacuum.



Nearly-free single magnetic domain wall of NiFe semicircular wire loop

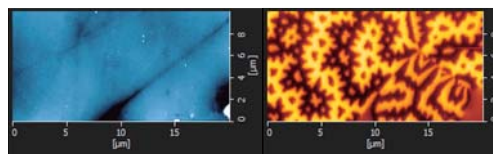


Topography

MFM

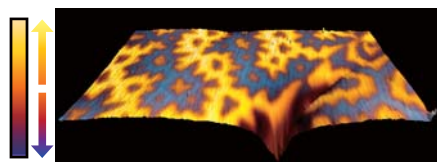
overlay

Magnetic domains of a thermally demagnetized Nd-Fe-B sintered magnet



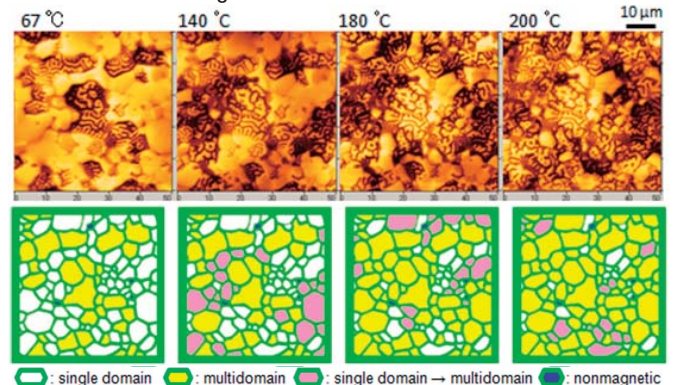
Topography

MFM



3D overlay image

Vacuum MFM measurement of *in situ* thermal demagnetization of Nd-Fe-B sintered magnet

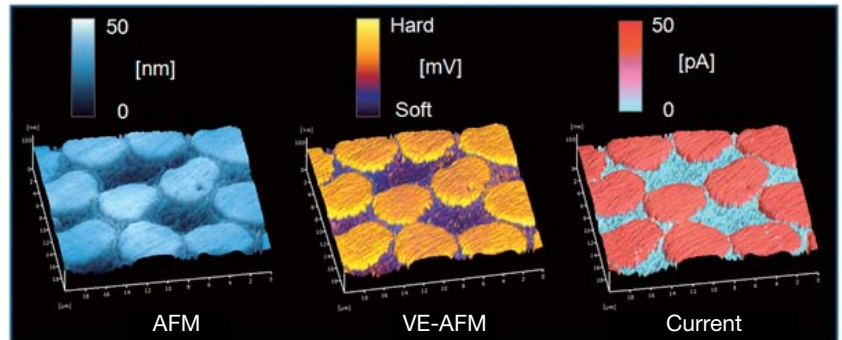


Legend: single domain (green), multidomain (yellow), single domain → multidomain (pink), nonmagnetic (blue)



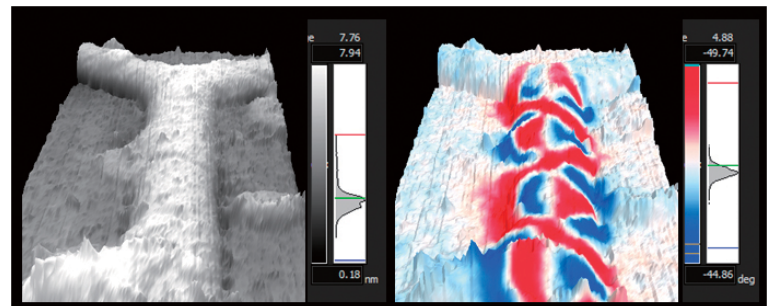
### AFM, VE-AFM, Current Measurements of Carbon Fiber Reinforced Polymer (CFRP)

CFRP is heavily used to make airplanes and automobiles light and robust. Since there are technical difficulties in its forming process and the interface structure, SPM's mechanical and electronic property measurements are increasingly important in the study of the material.



### High Resolution MFM Measurement of a Y-shaped Permalloy

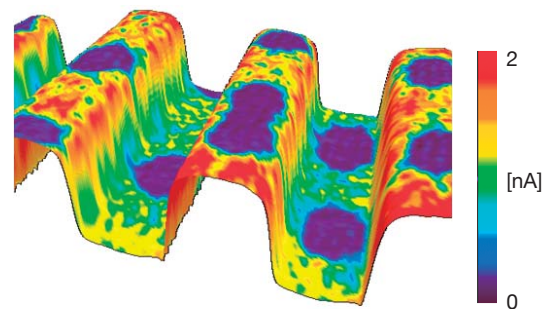
This Y-shaped permalloy dot (1.4  $\mu\text{m}$  length, 300 nm width and 130 nm thickness) is placed on a Si (100) substrate. Its magnetic micro structure is measured with high resolution MFM under vacuum. "Magnetic vortex" in longitudinal direction of the arm could be observed.



- Joint research with Tokyo University of Agriculture and Technology and NHK Laboratories  
- Scan area: 3  $\mu\text{m}$   $\times$  1.5  $\mu\text{m}$

### Recording Marks on Phase Change Optical Disk

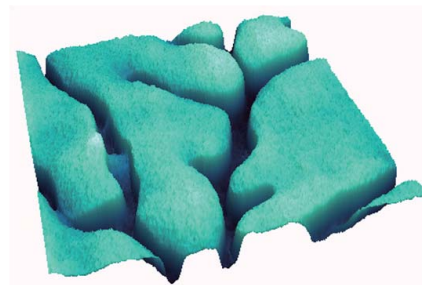
Phase change optical disks, such as DVD-RAM and CD-RW, are recorded by laser irradiation, changing their crystalline layer into an amorphous structure. Because of the difference between insulated recording marks and surrounding conductive crystalline layers, these marks can be observed by Current or KFM. In this example, recording marks on the land and groove areas are clearly visible.



- Scan area: 3  $\mu\text{m}$   $\times$  1.5  $\mu\text{m}$

### Poly (ethylene oxide) Thin Film

Poly (ethylene oxide) thin film prepared by slow cooling from the molten state, showing branch-like crystal lamellas with homogenous thickness (approximately 10 nm).



- Joint research with Tokyo Metropolitan University  
- Scan area: 2  $\mu\text{m}$

# Multifunctional Small Unit AFM5100N

The AFM5100N is user-friendly and supports a wide range of measurement modes. Flexible configurations and various accessories will meet the needs of all levels of SPM users.



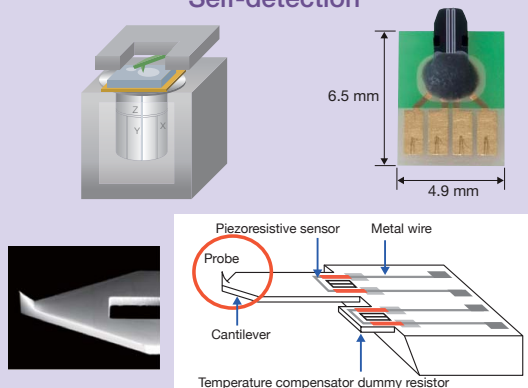
## Select your own configuration.

1

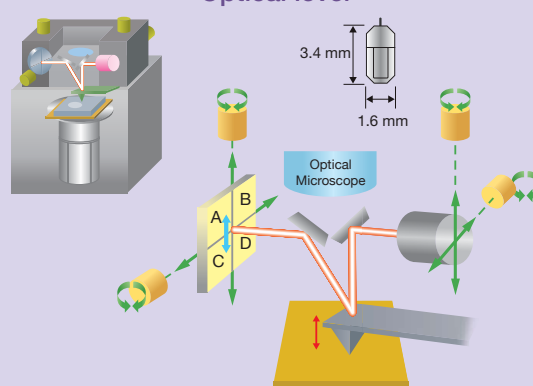
### Detection System

+

#### Self-detection



#### Optical lever



2

### Scanner

+

XY  
20  $\mu\text{m}$

Z: 1.5  $\mu\text{m}$

XY  
100  $\mu\text{m}$

Z: 15  $\mu\text{m}$

XY  
150  $\mu\text{m}$

Z: 5  $\mu\text{m}$

3

### Optical Microscope

+

#### Microscope with Cover



Lens magnification: x4

#### Desktop Zoom Microscope



Zoom ratio: x7

#### Zoom Microscope



Zoom ratio: x7

#### Metallurgical Microscope



Lens magnification:  
x5, x20, x50

4

### Anti-vibration

+

Desktop  
(passive)



### Accessories

+

### Multifunctional Modes



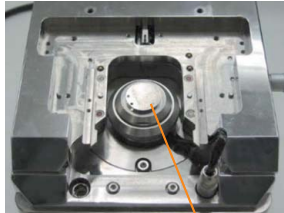
Floor model  
(passive)

## Detection System

The AFM5100N offers both Optical Lever System and Self-detection System. Optical Lever System supports electromagnetic and mechanical modes and is compatible with environmental controls, such as in-liquid and temperature control. You can achieve multiple measurements without exchanging the cantilever holder, since it can cover all measurements mode except STM and in-liquid imaging. Self-detection System simplifies difficult SPM operations. Its self-sensing cantilever has a sensor on itself, therefore this detection method does not require laser alignment. These two detection systems can be easily swapped by plugging in/out their cables to the main SPM unit.

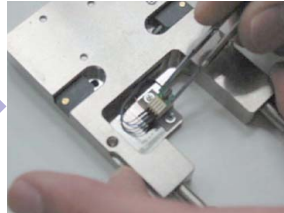
### Measurement flow of Self-detection System

Place a sample on the stage



Sample stage

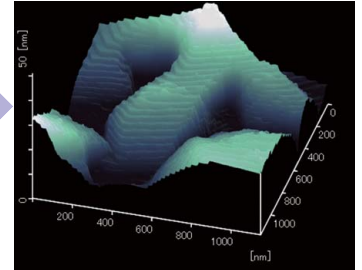
Mount the self-sensing cantilever



Mount Self-detection System and press "Start"



RealTune™II will automatically adjust parameters



The self-sensing cantilever has a piezoresistive sensor, assembled by MEMS technology. The cantilever can be easily exchanged, since it is mounted on a substrate, which makes it easy to grip the cantilever. The cantilever bends from a force that acts on the probe, changing the resistance of the piezoresistive sensor in the narrow part of the cantilever. Cantilever's deflection changes the resistance, which is detected by the bridge circuit together with the resistance of the temperature compensator dummy resistor.

## Optical Microscope

### Metallurgical Microscope

Metallurgical Microscope enables precise positioning of a cantilever.

#### Crystallinity in polymer



Optical microscope  
(Epi-illumination)



Metallurgical microscope  
(Polarized light)

#### Patterns on a silicon wafer



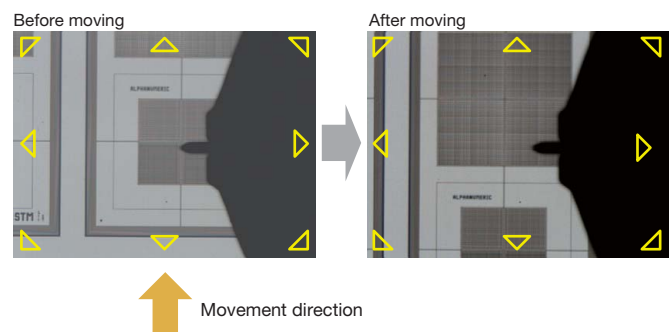
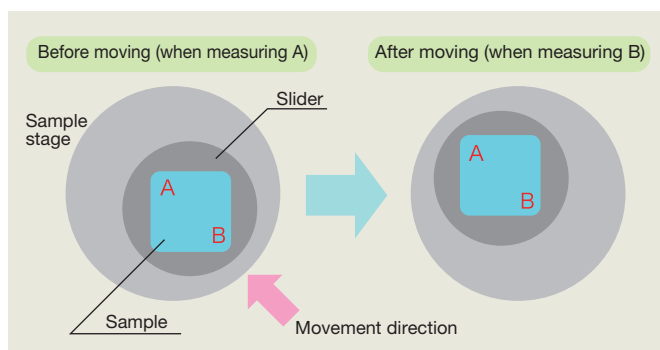
Optical microscope  
(Epi-illumination)



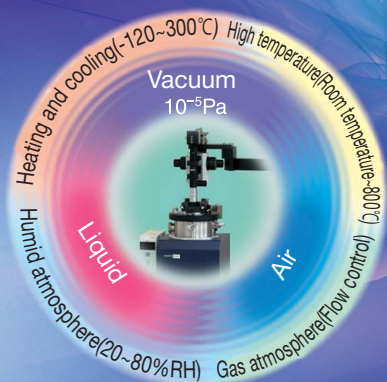
Metallurgical microscope  
(Polarized light)

## Impact Stage (optional)

The impact stage is a function that can easily change measurement positions by the operation on the screen display. This greatly improves operability for measuring multiple locations on the same sample.







## Environment Control Unit AFM5300E

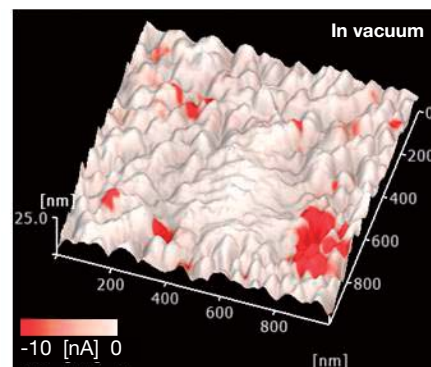
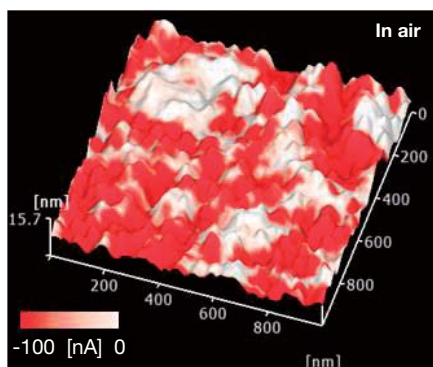
The AFM5300E is a high vacuum scanning probe microscope which provides various measurement conditions, such as air, liquid, vacuum, humidity control, and temperature control. Its vacuum chamber enables clear and high resolution observations of electromagnetic properties and in-situ observations at high and low temperatures.



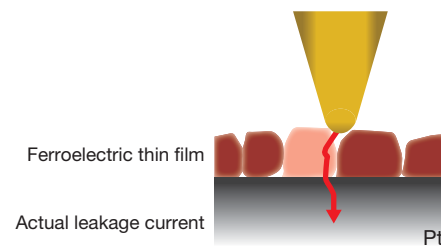
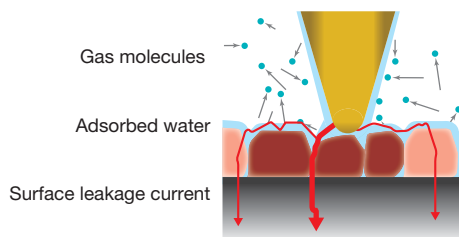
## High Vacuum System

AFM5300E's vacuum chamber meets the demand of advanced environment control needs. Some advanced materials and precise measurements of electromagnetic properties require a vacuum environment where adsorbed water and gas molecules are reduced.

Leakage current observations of a ferroelectric thin film on the right is an example of how vacuum environment can enhance the accuracy of current measurements.



Leakage current observations of a ferroelectric thin film

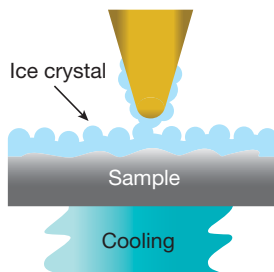


## Temperature Control

When the temperature in air falls below the dew point, ice will form on the surface. Even with a dried gas that has as little water vapor as possible, ice gradually forms when cooled below 0°C. In a vacuum environment created by the AFM5300E's turbo molecular pump, changes in topography and physical properties can be investigated while cooling down the sample to -120°C.

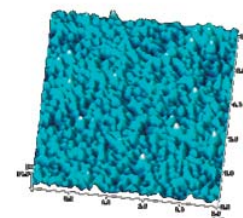
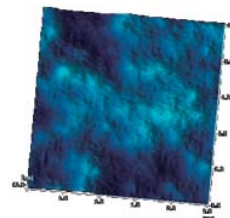
Cooling of polymer samples can also reveal unique characteristics of polymer nanostructures. Phase images on the right show thermal behavior of blended polymer at different temperatures. There is no distinctive differences between natural and synthetic rubbers. At -10°C, however, the natural rubber becomes harder than artificial one which visualize the distribution.

### Problem of ice accretion in air

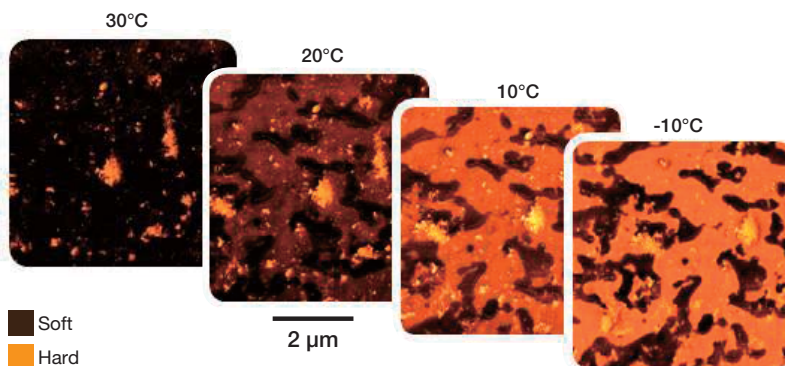


RT ~ -100°C

-130°C (Ice crystal)



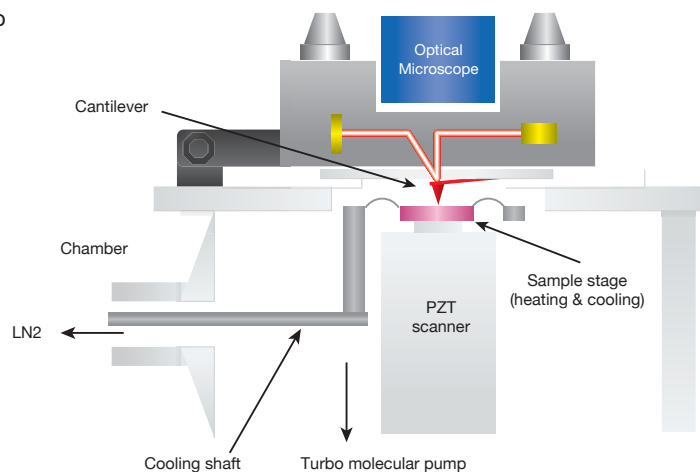
There is no ice accretion until -100°C in high vacuum



## Simple and Easy Operation

A tool-free open-close mechanism is employed. It is not necessary to align the laser after removing and mounting another sample and to exchange the cantilever holder when switching the measurement modes.\*

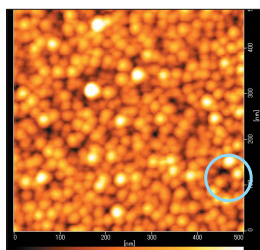
\*Except STM and in-liquid imaging.



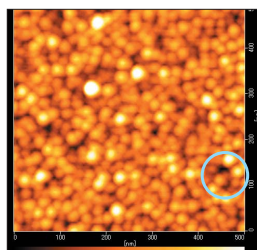
## Established Excellent High Performance

Swing Cancellation Mechanism achieved drastic reduction of drift. This mechanism improves and stabilizes SPM data.

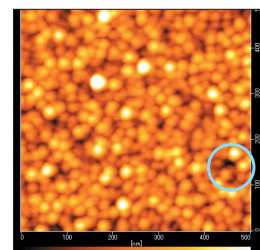
Au grains (500 nm<sup>2</sup>)



Right after approaching



After 20 minutes



After 40 minutes



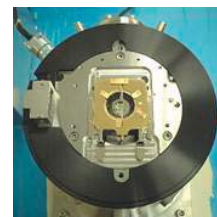
# Versatility

## In-situ Observations Optional Accessories

The AFM5300E supports various environments including in air, vacuum, liquid, temperature control, and humidity control.

### In Liquid

Unlike most conventional UHV systems, AFM5300E supports in-liquid imaging by mounting the cantilever holder expansion flange and exchanging the cantilever holder.



### Temperature Control

AFM5300E enables wide range of temperature control from -120°C to 300°C/ from room temperature to 800°C. Its vacuum system helps temperature control to be stable.



Temperature Controller



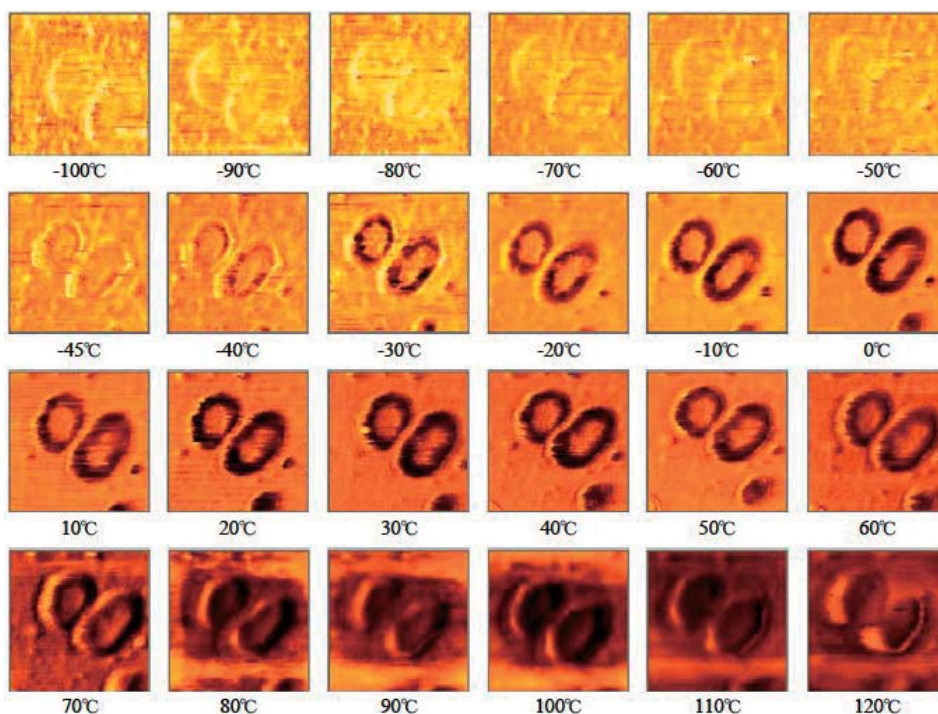
Heating and Cooling Temperature Control Module  
-120°C ~ 300°C



High Temperature Sample Stage  
RT ~ 800°C

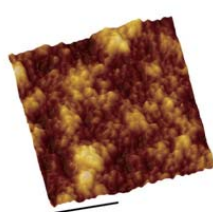
VE-AFM image of  
polypropylene  
block copolymer

■ Soft  
■ Hard

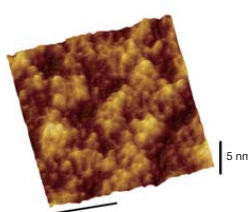


### Humidity Control

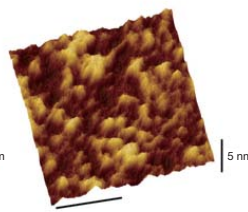
Observations of solid polymer electrolyte membrane for fuel cell in dry condition, high humidity and liquid.



Dry condition  
(10%)



High humidity  
(80%)



In pure water





## Air Protection Sample Holder Unit

Some materials are prone to oxidation or changing chemical/physical state under atmospheric conditions. The AFM5300E with optional Air Protection Sample Holder Unit offers imaging without exposure to the atmosphere. This unit has a vacuum enclosure that is sealed in situ allowing for safe and easy transfer to the SEM\*/ the Ion Milling System\*\* within an inert or vacuum environment.

\*Compatible with Hitachi FE-SEM with Air Protection Specimen Exchange Chamber.

\*\*Compatible with Hitachi IM4000 Ion milling System with Air Protection Holder Unit.



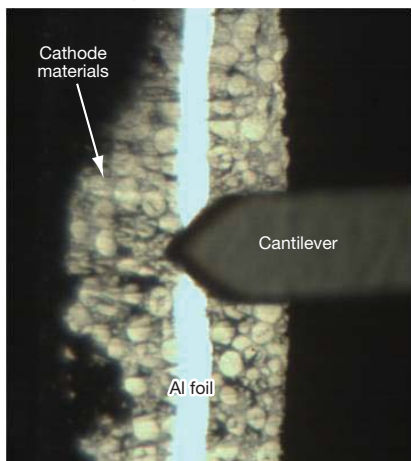
Sample Holder

### Example

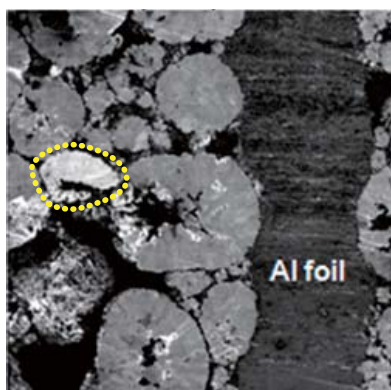
#### Observation of the same milled area of Li-ion battery cathode materials with FE-SEM and SSRM

- The electric resistance distribution of highly conductive Al foil and various cathode materials (micro-cathode active materials, a conductive assistant, and resin binders) on both sides are clearly observed in the SSRM image.
- The correlation between SSRM and FE-SEM images is shown. The active material, indicated by the dotted circles on (b) and (c), exhibits a brighter contrast on the SEM image and lower resistance on the SSRM image.
- The image (a) is captured by the metallurgical microscope's video camera attached to the AFM5300E. The top-view and high-magnification optical microscope significantly enhances the ease of use and enables SEM-SPM measurements of the same area.

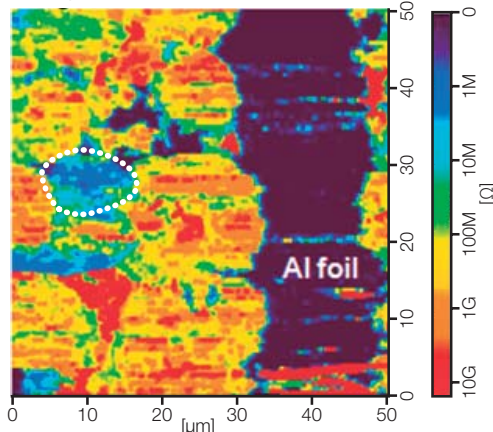
(a) Ion Milling



(b) FE-SEM (1keV)



(c) High Vacuum SSRM

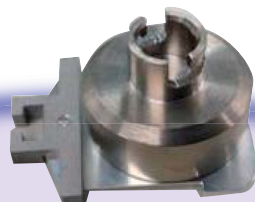


IM4000



### Ion Milling

Cross section milling  
Flatmilling



Air Protection Sample Holder

SU8200 Series



SE  
BSE  
EDX, EBSD  
SEM

AFM5300E



Topography  
Physical properties

SPM

# Specifications

## Probe Station AFM5000II

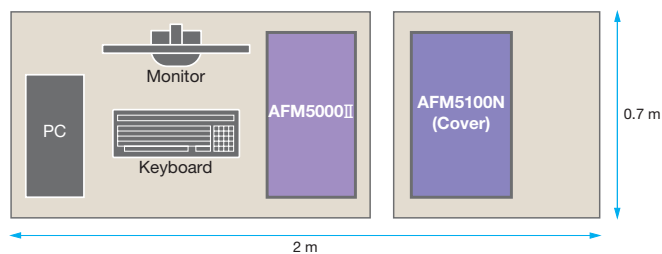


	AFM5000II
OS	Windows®7
Compatible Units	AFM5100N AFM5300E
RealTune™ II	Automatic tuning of cantilever amplitude (DFM), contact force, scan speed, and feedback gains (Various tuning modes including Auto, Fast, Soft, Rough, Flat, and Point)
Various Functions	Operating instructions; Tab structure (Measurement/ Analysis); Measurment area indicator/ Measurement area tracking window; Batch processing; and Tip calibration
Operating Voltage	XY (±200 V/18 bit) Z (±200 V/26 bit)
Multi Channel (Data Points)	4 channels (max. 2,048 × 2,048) 2 channels (max. 4,096 × 4,096)
Rectangular Scan	1:1, 2:1, 4:1, 8:1, 16:1, 32:1, 64:1, 128:1, 256:1, 512:1, 1,024:1
Analysis Software	3D display and overlay, Roughness, Cross-section, Average cross-section
Size	220 mm(W) × 500 mm(D) × 385 mm(H), approximately 15 kg
Power Supply	AC 100 V ~ 240 V±10%

## Installation layout

### AFM5100N

(Floor model anti-vibration table)



## AFM5100N

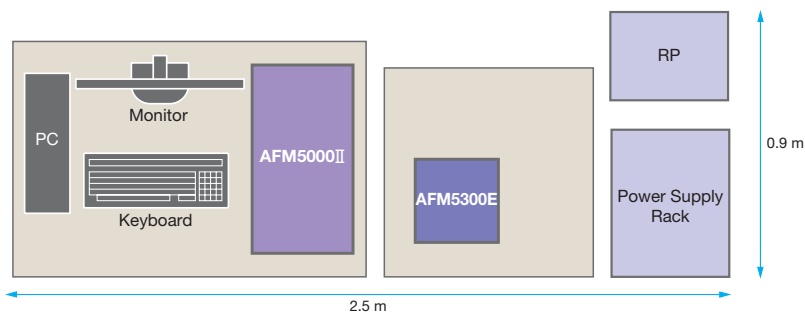


## AFM5300E



	AFM5100N	AFM5100N Optional Accessories	AFM5300E	AFM5300E Optional Accessories
Manual Stage	XY $\pm 2.5$ mm	Impact Stage	XY $\pm 2.5$ mm	—
Sample Size	35 mm (diameter) Thickness: 10 mm	2 inch Adjustment Block 50.08 mm x 50.08 mm x 20 mm	25 mm (diameter) Thickness: 10 mm	—
Scan Range (Select at least one)	20 $\mu$ m x 20 $\mu$ m x 1.5 $\mu$ m 100 $\mu$ m x 100 $\mu$ m x 15 $\mu$ m 150 $\mu$ m x 150 $\mu$ m x 5 $\mu$ m	Closed loop scanner 110 $\mu$ m x 110 $\mu$ m x 6 $\mu$ m	20 $\mu$ m x 20 $\mu$ m x 1.5 $\mu$ m	100 $\mu$ m x 100 $\mu$ m x 15 $\mu$ m 150 $\mu$ m x 150 $\mu$ m x 5 $\mu$ m Closed loop scanner XY: 15 $\mu$ m
Detection	Self-Detection/ Optical Lever (Select at least one)	—	Optical Lever (Low-coherence light)	
Optical Microscope (Select at least one)	Microscope with Cover (Lens magnification: x4) Desktop Zoom Microscope (Lens magnification: x7) Zoom Microscope (Lens magnification: x7) Metallurgical Microscope (Lens magnification: x5, x20, x50)		Zoom Microscope (Lens magnification: x7) Metallurgical Microscope (Lens magnification: x5, x20, x50)	
Anti-vibration	Desktop Floor model (Select at least one or supply equivalent table top vibration isolation.)		Floor model (The main AFM unit is integrated with the vibration isolation table.)	
Temperature Control	—	In air: RT $\sim$ 250°C In liquid: RT $\sim$ 60°C	—	-120°C $\sim$ 300°C RT $\sim$ 800°C In liquid: RT $\sim$ 60°C
In Liquid	—	✓	—	✓
Humidity Control	—	—	—	✓ 20 $\sim$ 80%RH
Vacuum	—	—	—	Turbo-molecular Pump & Rotary Pump (9.9 x 10 <sup>-6</sup> pa)

### AFM5300E





# Hitachi High-Tech Science

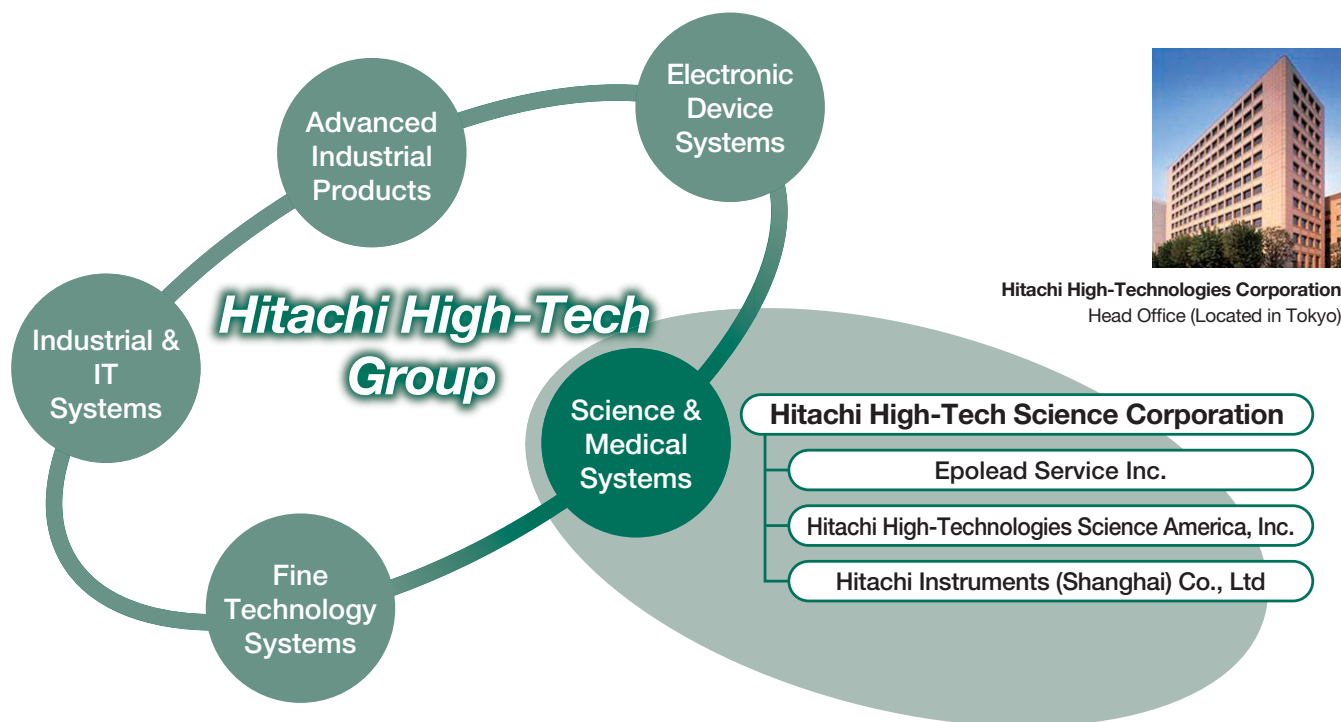
In 2013, Hitachi High-Tech Science Corporation has made a new start as a member of the Hitachi High-Technologies Group.

Since opening its doors in the 1970s, Hitachi High-Tech Science has cultivated unique technologies and produced numerous innovative analytical and measurement instruments.

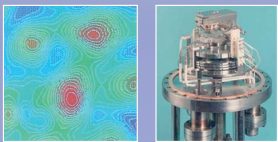

Those products based on our high precision technologies are used in industrial fields that include electronic devices, environment, materials, and clean energy, as well as for research support at universities and research institutes.

Our aim as a member of the Hitachi High-Technologies Group is to be a successful enterprise, one trusted by our stakeholders, providing advanced products that satisfy market needs.

Hitachi High-Tech Science is actively pursuing development that skillfully balances scientific technologies with the global society.



# History

	Hitachi High-Tech Science Corporate History	Hitachi High-Tech Science' SPM Product History	History of SPM
1970s ●	1970 Daini Seikosha, current Seiko Instruments Inc., established an R&D Center and entered into the business of scientific instruments		
1980s ●		1985 STM research & development with the National Institute of Advanced Industrial Science and Technology (AIST) 1986 First AFM observation (NbSe <sub>2</sub> ) in Japan by AIST  1988 Commercialization of Japan's first STM (SAM3000)	1981 First STM observation of atoms by Dr. Binnig, Dr. Rohrer (IBM Zurich Laboratory) 1986 AFM development by Dr. Binnig (IBM), Dr. Quate (Stanford University) Dr. Binnig, Dr. Rohrer received the Noble Prize in Physics
1990s ●		1991 Japan's first AFM (SFA300) 1992 Japan's first SPM (SPA300)  Main unit: SPA-400 SPA-300HV SPA-250, SPA-260, SPA-270, SPA-500 Controller: SPI3600 SPI3700 SPI3800	
2000s ●	2000 Seiko Instruments founded SII Microscope Inc. 2003 SII Microscope Inc. changed company name to SII NanoTechnology Inc. SII NanoTechnology succeeded the scientific instruments business of Seiko Instruments by partition of corporation	Main unit: Nanocute S-image E-sweep L-trace L-traceII Controller: SPI4000 NanoNavi NanoNaviII	
2010s ●	2013 Became a member of Hitachi High-Technologies Group and officially changed company name to Hitachi High-Tech Science Corporation. Company head office moved to Minato-ku, Tokyo Hitachi High-Tech Science succeeded Design & Development, QA and Domestic Sales section of analytical instruments business from Hitachi High-Technologies	Main unit: AFM5100N AFM5200S AFM5300E AFM5400L Controller: AFM5000 (NanoNavi Real) AFM5000II	



## Science Ring

The Hitachi High-Tech Group aims to be a global leader in the “Observation”, “Measurement” and “Analysis” scientific and analysis fields, maintains points of contact with customers in a wide range of disciplines and actively works to provide advanced high added value solutions.

The logo mark is centered on the “S” from “Science”, which represents the form created and connected through our cooperation as a good partner to customers and society that has its roots in our technologies, and which is expressed as organic spheres encircled by a ring. It indicates our promise to society to create value through high-tech solutions that connect science and society.

The above logo is a registered trademark of Hitachi High-Technologies in Japan and other countries.

Note: •To ensure safe operation, follow the instruction manual when using the instrument.

•System specifications are subject to change without notice.

•The PC monitor shows composite images.

•“Windows” is a registered trademark of Microsoft Corporation in the United States and other countries.

## Hitachi High-Technologies Corporation

### Head Office

24-14, Nishi-Shimbashi 1-chome, Minato-ku, Tokyo 105-8717, Japan

[contact@nst.hitachi-hitec.com](mailto:contact@nst.hitachi-hitec.com)

[www.hitachi-hitec.com/global/science/](http://www.hitachi-hitec.com/global/science/)

## Hitachi High-Tech Science Corporation

### Head Office Sales Division

24-14, Nishi-Shimbashi 1-chome, Minato-ku Tokyo 105-0003, Japan

[www.hitachi-hightech.com/global/hhs/](http://www.hitachi-hightech.com/global/hhs/)

Telephone : +81-3-6280-0062